

HI516

16 Channel/Differential 8 Channel CMOS High Speed Analog Multiplexer

The HI-516 is a monolithic dielectrically isolated, high speed, high performance CMOS analog multiplexer. It offers unique built-in channel selection decoding plus an inhibit input for disabling all channels.

The dual function of address input A_3 enables the HI-516 to be user programmed either as a single ended 16-channel multiplexer by connecting 'out A' to 'out B' and using A_3 as a digital address input, or as an 8-channel differential multiplexer by connecting A_3 to the V- supply. The substrate leakages and parasitic capacitances are reduced substantially by using the Harris Dielectric Isolation process to achieve optimum performance in both high and low level signal applications. The low output leakage current ($I_{DOFF} < 100pA$ at $+25^{\circ}C$) and fast settling ($I_{SETTLE} = 800ns$ to 0.01 %) characteristics of the device make it an ideal choice for high speed data acquisition systems, precision instrumentation, and industrial process control.

Rochester Electronics Manufactured Components

Rochester branded components are manufactured using either die/wafers purchased from the original suppliers or Rochester wafers recreated from the original IP. All re-creations are done with the approval of the Original Component Manufacturer (OCM).

Parts are tested using original factory test programs or Rochester developed test solutions to guarantee product meets or exceeds the OCM data sheet.

Quality Overview

- ISO-9001
- AS9120 certification
- Qualified Manufacturers List (QML) MIL-PRF-35835
 - Class Q Military
 - Class V Space Level
- Qualified Suppliers List of Distributors (QSLD)
 - Rochester is a critical supplier to DLA and meets all industry and DLA standards.

Rochester Electronics, LLC is committed to supplying products that satisfy customer expectations for quality and are equal to those originally supplied by industry manufacturers.

The original manufacturer's datasheet accompanying this document reflects the performance and specifications of the Rochester manufactured version of this device. Rochester Electronics guarantees the performance of its semiconductor products to the original OCM specifications. 'Typical' values are for reference purposes only. Certain minimum or maximum ratings may be based on product characterization, design, simulation, or sample testing.

FOR REFERENCE ONLY



HI-516

16 Channel/Differential 8 Channel **CMOS High Speed Analog Multiplexer**

December 1993

Features

- · Access Time (Typical) 130ns
- Settling Time 250ns (0.1%)
- Low Leakage (Typical)
 - I_{S(OFF)} 10pA
 - I_{D(OFF)} 30pA
- · Low Capacitance (Max)
 - C_{S(OFF)} 10pF
 - C_{D(OFF)} 25pF
- · Off Isolation at 500kHz 55dB (Min)
- Low Charge Injection Error 20mV
- Single Ended to Differential Selectable (SDS)
- · Logic Level Selectable (LLS)

Applications

- Data Acquisition Systems
- Precision instrumentation
- Industrial Control

Description

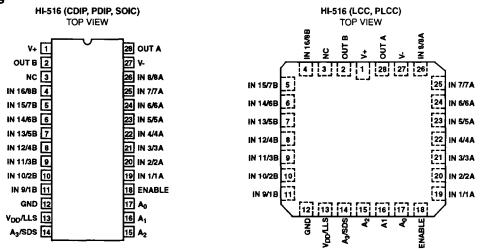
The HI-516 is a monolithic dielectrically isolated, high speed, high performance CMOS analog multiplexer. It offers unique built-in channel selection decoding plus an inhibit input for disabling all channels. The dual function of address input A₃ enables the HI-516 to be user programmed either as a single ended 16-channel multiplexer by connecting 'out A' to 'out B' and using A3 as a digital address input, or as an 8-channel differential multiplexer by connecting A3 to the V- supply. The substrate leakages and parasitic capacitances are reduced substantially by using the Harris Dielectric Isolation process to achieve optimum performance in both high and low level signal applications. The low output leakage current (IDOFF < 100pA at +25°C) and fast settling (t_{SETTLE} = 800ns to 0.01%) characteristics of the device make it an ideal choice for high speed data acquisition systems, precision instrumentation, and industrial process control.

For MIL-STD-883 compliant parts, request the HI-516/883 data sheet.

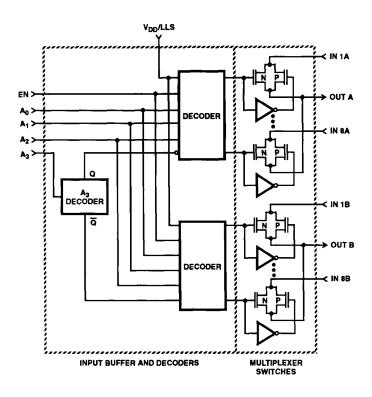
Ordering Information

PART NUMBER	TEMP. RANGE	PACKAGE
HI4P0516-5	0°C to +75°C	28 Lead PLCC
HI3-0516-5	0°C to +75°C	28 Lead Plastic DIP
HI1-0516-5	0°C to +75°C	28 Lead Ceramic DIP
HI1-0516-2	-55°C to +125°C	28 Lead Ceramic DIP
HI1-0516-8	-55°C to +125°C	28 Lead Ceramic DIP
HI4-0516-8	-55°C to +125°C	28 Lead Ceramic LCC
HI9P0516-5	0°C to +75°C	28 Lead SOIC
HI9P0516-9	-40°C to +85°C	28 Lead SOIC
HI1-0516/883	-55°C to +125°C	28 Lead Ceramic DIP
HI4-0516/883	-55°C to +125°C	28 Lead Ceramic LCC

Pinouts



Functional Block Diagram



A ₃ DECODE								
A ₃	q	ā						
н	н	L						
L	L	н						
V-	L	L						

Specifications HI-516

Absolute Maximum Ratings (Note 1)	Thermal Information		
Voltage Between Supply Pins	Thermal Resistance Plastic DIP Package Plastic SOIC Package Plastic PLCC Package Ceramic DIP Package Ceramic LCC Package Junction Temperature Ceramic DIP, Ceramic LCC Plastic DIP, Plastic SOIC, Plastic PLCC Operating Temperature Ranges HI-516-2,-8 HI-516-5 HI-516-9	55°C	+150°C to +125°C C to +75°C

CAUTION: Stresses above those listed in "Absolute Maximum Ratings" may cause permanent damage to the device. This is a stress only rating and operation of the device at these or any other conditions above those indicated in the operational sections of this specification is not implied.

Electrical Specifications Supplies = +15V, -15V; V_{AH} (Logic Level High) = +2.4V, V_{AL} (Logic Level Low) = +0.8V; V_{DD}/LLS = GND. (Note 1) Unless Otherwise Specified

	TEST		HI-516-2, -8			1	HI-516-5, -9		
PARAMETER	CONDITIONS	TEMP	MIN	TYP	MAX	MIN	TYP	MAX	UNITS
ANALOG CHANNEL CHARACTER	RISTICS								
Analog Signal Range, V _I	Note 2	Full	-14	-	+14	-15	-	+15	٧
On Resistance, R _{ON}	Note 3	+25°C	-	620	750		620	750	Ω
		Full	-	-	1,000	-		1,000	Ω
Off Input Leakage Current, Is(OFF)		+25°C	-	0.01	<u> </u>	-	0.01	- -	nA
		Full	-	-	50	-	-	50	nA
Off Output Leakage Current,		+25°C		0.03	-	-	0.03	1.	nA
D(OFF)		Full	- 1	-	100	-	-	100	nA
On Channel Leakage Current,		+25°C	. 1	0.04	· ·	-	0.04	<u> </u>	nA
Î _D (ON)		Full	-	<u> </u>	100	-	-	100	nA
DIGITAL INPUT CHARACTERIST	ics								
Input Low Threshold, V _{AL} (TTL)		Full	-		0.8		-	8.0	٧
Input High Threshold, V _{AH} (TTL)		Full	2.4	-	· ·	2.4	-	-	V
input Low Threshold, V _{AL} (CMOS)		Full		-	0.3V _{DD}	-	-	0.3V _{DD}	V
Input High Threshold, V _{AH} (CMOS)		Fuil	0.7V _{DD}	-	-	0.7V _{DD}	-	-	٧
Input Leakage Current, I _{AH} (High)		Full	•	-	1	- 1		1	μА
Current, I _{AL} (Low)		Full	-	-	25	-	-	25	μA
SWITCHING CHARACTERISTICS	;								
Access Time, t _A		+25°C	<u> </u>	130	175	-	130	175	ns
		Full			225	- 1	-	225	ns
Break-Before-Make Delay, t _{OPEN}		+25°C	10	20		10	20	-	ns
Enable Delay (ON), t _{ON(EN)}		+25°C	-	120	175	-	120	175	ns
Enable Delay (OFF), t _{OFF(EN)}		+25°C	-	140	175	- -	140	175	ns
Settling Time									
0.1%	l!	+25°C	-	250	.	. 1	250		ns
0.01%		+25°C	-	800	-	-	800	<u> </u>	ns
Charge Injection Error	Note 4	+25°C	- 1		20	-		20	mV

Specifications HI-516

Electrical Specifications Supplies = +15V, -15V; V_{AH} (Logic Level High) = +2.4V, V_{AL} (Logic Level Low) = +0.8V; V_{DD}/LLS = GND. (Note 1) Unless Otherwise Specified (Continued)

	TEST CONDITIONS	TEMP	H⊦516-2, -8			HI-516-5, -9			
PARAMETER			MIN	TYP	MAX	MIN	TYP	MAX	UNITS
SWITCHING CHARACTERISTIC	CS (Continued)					-			
Off Isolation	Note 5	+25°C	55		-	55	-		dΒ
Channel Input Capacitance,		+25°C	-	-	10	-	-	10	pF
Channel Output Capacitance, C _{D(OFF)}		+25°C	-	-	25	-	-	25	pF
Digital Input Capacitance, CA		+25°C	-		10	-		10	pF
Input to Output Capacitance, CDS(OFF)		+25°C	-	0.02		-	0.02	-	pF
POWER SUPPLY CHARACTER	RISTICS								
Power Dissipation, PD		Full	-		750	-	-	900	mW
I+, Current	Note 6	Full	-	-	25	-	· -	30	mA
I-, Current	Note 6	Full	-		25		-	30	mA

NOTES:

- 1. V_{DD}/LLS pin = open or grounded for TTL compatibility. V_{DD}/LLS pin = V_{DD} for CMOS compatibility.
- 2. At temperatures above +90°C, care must be taken to assure V_{IN} remains at least 1.0V below the V_{SUPPLY} for proper operation.
- 3. $V_{IN} = \pm 10 V$, $I_{OUT} = -100 \mu A$.
- 4. $V_{IN} = 0V$, $C_L = 100 pF$, enable input pulse = 3V, f = 500 kHz.
- 5. $V_{EN} = 0.8V$, $V_S = 3V_{RMS}$, f = 500kHz, $C_L = 40pF$, $R_L = 1K$, Pin 3 grounded.
- 6. $V_{EN} = +2.4V$.

TRUTH TABLE HI-516 Used as a 16-Channel Multiplexer or 8-Channel Differential Multiplexer (Note 1)

TRUTH TABLE HI-516 Used as a Differential 8-Channel Multiplexer

USE A ₃ AS	DIGITA	ON CHANNEL TO				
ENABLE	A ₃	A ₂	A ₁	Ao	OUT A	OUT B
L	X	Х	Х	Х	None	None
Ħ	L	L	L	L	1A	None
Ξ	Ļ	L	L	Н	2A	None
н	L	L	Н	L	3A	None
н	L	L	Н	Н	4A	None
H	L	Н	L	L	5A	None
н	L	Н	L	Н	6A	None
Н	L	н	Н	L	7A	None
н	L	Н	Н	Н	8A	None
Н	Н	L	L	L	None	1B
Н	Н	L	L	Н	None	2B
Н	Н	L	н	L	None	3B
Н	Н	L	Н	Н	None	4B
Н	Н	Н	L	L	None	5B
Н	Н	Н	L	Н	None	6B
н	Н	Н	Н	L	None	7B
Н	Н	Н	Н	Н	None	8B

A ₃ CON	IECT TO	ON CHANNEL TO			
ENABLE	A ₂	A ₁	A ₀	OUT A	OUT B
L	X	_ X	X	None	None
Н	L	L	L	1A	1B
н	L	L	Н	2A	2B
Н	L	Н	L	3A	3B
н	L	Н	Н	4A	4B
Н	н	L	L	5A	5B
Н	Н	L	Н	6A	6B
Н	Н	Н	L	7A	7B
Н	Н	Н	Н	8A	8B

NOTE:

 For 16-channel single-ended function, tie 'out A' to 'out B', for dual 8-channel function use the A₃ address pin to select between MUX A and MUX B, where MUX A is selected with A₃ low.

Test Circuits

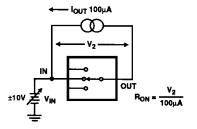


FIGURE 1. ON RESISTANCE VS INPUT SIGNAL LEVEL

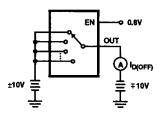


FIGURE 2. I_{D(OFF)} (NOTE 1)

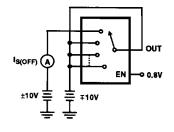


FIGURE 3. I_{S(OFF)} (NOTE 1)

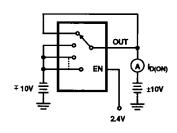


FIGURE 4. I_{D(ON)} (NOTE 1)

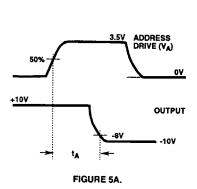
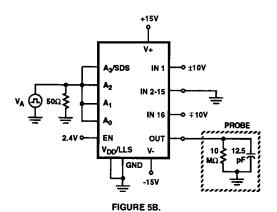


FIGURE 5. ACCESS TIME



NOTE:

1. Two measurements per channel: $\pm 10V$ and $\mp 10V$. (Two measurements per device for $I_{D(OFF)} \pm 10V$ and $\mp 10V$)

HI-516 Test Circuits (Continued) +15V 3.5V IN 1 **ADDRESS** IN 2-15 DRIVE (VA) 07 IN 16 - OUTPUT A OUT ΕN V_{DD}/LLS GND FIGURE 6A. ENABLE DRIVE FIGURE 6B. FIGURE 6. BREAK-BEFORE-MAKE DELAY (topen) +15V 3.57 07 OUTPUT A IN 2-16 ^tON(EN) EN OUT → toff(EN) V_{DD}/LLS GND -15V FIGURE 7A. ENABLE DRIVE FIGURE 7B. FIGURE 7. ENABLE DELAY ton(EN), toff(EN) +15V 3.0V A₃/SDS 07 ΔV_{O} OUT A OR B CL = 100pF

 $\label{eq:delta-def} \textbf{FIGURE 8A.}$ ΔV_O is the measured voltage error due to charge injection. The error voltage in coulombs is Q = C_L x ΔV_O

FIGURE 8. CHARGE INJECTION TEST CIRCUIT

-15V

FIGURE 8B.

Die Characteristics

DIE DIMENSIONS:

2250µm x 3720µm x 485µm ±25µm

METALLIZATION:

Type: CuAl

Thickness: 16kÅ ± 2kÅ

GLASSIVATION:

Type: Nitride Over Silox Nitride Thickness: 3.5kÅ ± 1kÅ Silox Thickness: 12kÅ ± 2kÅ

WORST CASE CURRENT DENSITY: 1.64 x 10⁵A/cm²

Metallization Mask Layout

HI-516

